

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**Applicant(s):** Kwang Choe et al.

**Examiner:** Padgett, Marianne L.

**Serial No.:** 10/674,648

**Art Unit:** 1792

**Filed:** September 30, 2003

**Docket No.:** YOR920030294US1 (16817)

**Title:** SOI BY OXIDATION OF  
POROUS SILICON

**Date:** September 24, 2008

**Confirmation No.:** 4794

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA. 22313

**RESPONSE AND AMENDMENT UNDER 37 C.F.R. § 1.111**

Sir:

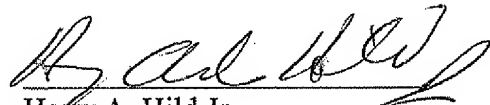
In response to the Office Action dated June 25, 2008, Applicants submit the following amendments and remarks for entry of record in the above-identified application.

---

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on September 24, 2008.

Dated: September 24, 2008

  
Harry A. Hild Jr